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			First Named Inventor		F. Venema
			Art Unit		1634
			Examiner Name		Amanda M. Shaw
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U.S. PATENT DOCUMENTS					
Examiner Initials*	Cite No.	Document Number	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear
		Number-Kind Code (if known)			
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FOREIGN PATENT DOCUMENTS						
Examiner Initials*	Cite No.	Foreign Patent Document	Publication Date MM-DD-YYYY	Name of Patentee or Applicant of Cited Document	Pages, Columns, Lines, Where Relevant Passages or Relevant Figures Appear	T
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NON PATENT LITERATURE DOCUMENTS					
Examiner Initials*	Cite No.	Include name of the author (in CAPITAL LETTERS), title of the article (when appropriate), title of the item (book, magazine, journal, serial, symposium, catalog, etc.), date, page(s), volume-issue number(s), publisher, city and/or country where published			T
	1.	HUANG and LI. "Characterization of the 5' to 3' Nuclease Activity of <i>Thermus aquaticus</i> DNA Polymerase on Fluorogenic Double-Stranded Probes" <i>Molecular and Cellular Probes</i> 23 :188-194 (2009)			
	2.	KAISER et al. "A Comparison of Eubacterial and Archaeal Structure-Specific 5'-Exonucleases" <i>The Journal of Biological Chemistry</i> 274 (30):21387-21394 (1994)			
	3.	LYAMICHEV et al. "Structure-Specific Endonucleolytic Cleavage of Nucleic Acids by Eubacterial DNA Polymerases" <i>Science</i> 260 :778-783 (1993)			

Examiner Signature		Date Considered	
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